



FORM PTO-1449

INFORMATION DISCLOSURE CITATION  
IN AN APPLICATION PURSUANT TO  
37 CFR §1.97 & 1.98Docket Number: 4795-004  
Serial Number: 10/078,720Applicant:  
Ye et al.Filing Date: February 19, 2002  
Group: 1725U. S. PATENT DOCUMENTS

Examiner							Filing Date	
Initial	Patent No.	Date	Name	Class	Subcl	If Approp.		
AE	A 6,140,708	2000	Lee et al.					

FOREIGN PATENT DOCUMENTS

							Translation	
	Patent No.	Date	Name	Class	Subcl	Yes	No	
AE	B WO 01/10177	2001	Conlon et al.					

OTHER DOCUMENTS (including author, title, date, pages, etc.)


EXAMINER

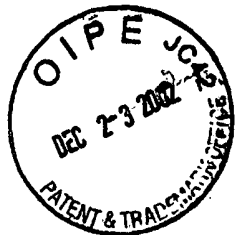
M. Alexandra Elve

DATE CONSIDERED

6/22/03

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YE Kaidong

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U. S. PATENT DOCUMENTS

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Initial	Patent No.	Date	Name	Class	Subcl	If Approp.
<i>KE</i>	A 6087618	2000	Wiener-Avneer et al			
<i>KE</i>	B 5624587	1997	Otsuki et al			
<i>KE</i>	C 4358659	1982	Spohnheimer			

FOREIGN PATENT DOCUMENTS

Translation

	Patent No.	Date	Name	Class	Subcl	Yes	No
<i>KE</i>	D EP 1093881	2001	Sumitomo Electric Ind Ltd				
<i>KE</i>	E DE 4034745	1991	Friedrich-Schiller-Universitat Jena				
<i>KE</i>	F WO 9814302	1998	Force Instituttet				
<i>KE</i>	G WO 9808414	1995	Laser Machining Inc				
<i>KE</i>	H JP 3099479	1991	Sanyo Electric Co				
<i>KE</i>	I TW 85112862	1996	Cristalleria Artistica La Piana				

OTHER DOCUMENTS (including author, title, date, pages, etc.)


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*M. Alexandra Elve**6/22/03*

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